

# **Durimide® 7500**Photosensitive Polyimide

## Precursor

• Designed with a unique structure and sensitizer that gives it the following characteristics:

Fast photospeed Enhanced resolution Wide process latitude Self priming Excellent adhesion

- Superior mechanical property retention after extended pressure cooker test (> 1000 hour)
- Cured film thickness range: 2-50µm

<u>lype</u>	<u>Viscosity</u>	Cured Film Thickness
Durimide® 7505	1200CS	2-5µm
Durimide® 7510	3300CS	4-15µm
Durimide® 7520	6400CS	11-25+µm

### **Compatible Ancillary Products:**

<u>Developer/Rinse Combinations</u>: <u>Back Side Rinse</u>: QZ3501/QZ3512 QZ3501 HTRD2/RER600 HTRD2

<u>Edge Bead Remover</u>: <u>Stripper Products:</u>

HTRD2 N-Methyl 2-Pyrrolidone

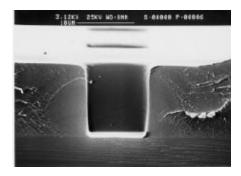
QZ 3322

# Cured Film Properties of Durimide® 7500 Series

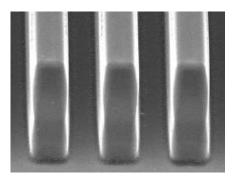
Tensile Strength	MPa	215
Young's Modulus	GPa	2.5
Tensile Elongation	%	85
Glass Transition Temperature	ပ္	285
Thermal Decomposition Temperature	ပ္	525
Coefficient of Thermal Expansion	ppm/°C	55
Dielectric Constant		3.2-3.3
Moisture Absorption@50% RH	%	1.08



Contact print resolution mask in 40µm softbake film



10μm via in a 10μm softbaked film, i-line stepper



12µm lines and spaces in a 44µm softbaked film, g-line stepper

### **Process Window**

Exp.Range 60-200mJ/cm2

**Focus Range** 4-8 microns into film

Substrate: Silicon

Soft Bake: 100°C /3mins

PI Thickness: 12µm

**Exposure Tool:** Canon i-line stepper

0.6NA, 0.5 sigma

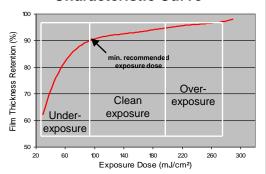
Post Exposure delay: 20-22°C/30 mins Developer/Rinse: HTRD2/RER600

30"/10"/15"

Cure: 350°C/ 60 mins

Cured Film Thickness: 6.2 µm

### Characteristic Curve



Process Summary:

Substrate: silicon

Soft Bake: 100°C /3mins

PIThickness: 10µm

Canon g-line stepper **Exposure Tool:** 

.43NA

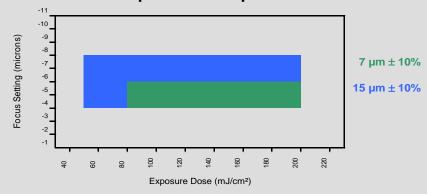
Post Exposure delay: 20-22°C/30 mins Developer/Rinse: HTRD2/RER600

30"/10"/15"

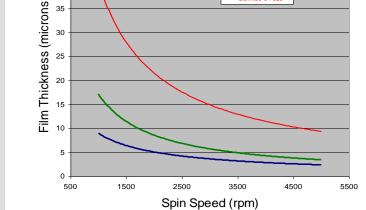
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# Process Window for a 7 & 15 µm CD space in a 12 µm film



**Cured Film Thickness vs. Spin Speed** 40 35 30



Durimide® 7500 undergoes a 45% shrinkage from softbake to cure.

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